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CVD Deposition and Characterization of Multilayers and Thin Films

Guest Editor:

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Message from the Guest Editor

Science and technology of thin films produced by CVD techniques, demonstrates a continuous progress due to the synthesis of new materials, adapting deposition parameters to demands of particular applications, better in situ control of reaction gas chemistry, and sophisticated methods for material characterization. CVD films are indispensable for the fabrication of electronic and photonic devices, surface coatings with special properties such as high hardness, wear and chemical resistance, low friction, superhydrophobicity, dielectric/conductive layers, bioactivity, and many others.

This Special Issue will be devoted to all aspects related to CVD films: growth, characterization and applications, to present the state-of-the-art in this rapidly developing field, with a special focus on multilayer structures and interface phenomena. Original research papers and review articles related to these areas are cordially invited.













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Message from the Editor-in-Chief

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